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FORM PTO-1449 Atty. Docket No. Application No. U.S. Department of Commerce Patent and Trademark Office P30152 10/596,780 Applicant INFORMATION DISCLOSURE STATEMENT Shinji INOUE et al. BY APPLICANT (Use several sheets if necessary) Filing Date Group 2169 June 23, 2006 Unknown-**U.S. PATENT DOCUMENTS** FILING DATE **EXAMINER SUBCLASS** IF APPROPRIATE NAME CLASS DATE INITIAL DOCUMENT NUMBER /T.V./ 06/06/02 MORITA et al. 2002 0 6 9 2 0 5 O /T.V./ 2006 9 5 7 2 08/31/06 INOUE et al. 0 1 6 /T.V./ 2006 0 0 5 0 6 2 2 03/09/06 SO et al. /T.V./ SO et al. 2005 0 2 3 1 7 6 5 10/20/05 /T.V./ 2005 2 1 6 6 8 4 09/29/05 SO et al. **FOREIGN PATENT DOCUMENTS** TRANSLATION COUNTRY CLASS SUBCLASS **DOCUMENT NUMBER** DATE /T.V./ 02/09/01 **JAPAN** 2001 3 4 5 1 /T.V./ **JAPAN** 2003 2 3 3 5 1 7 08/22/03 /T.V./ 2002 1 9 3 5 04/19/02 **JAPAN** 6 /T.V./ 2001 2 9 9 3 09/14/01 **JAPAN** 4 6 /T.V./ 00 02/07/00 W.I.P.O 7 4 0 5 4 OTHER DOCUMENTS (Including Author, Title, Date, Pertinent Pages, Etc.) English language Abstract of JP 2001-034515. /T.V./ 1 English language Abstract of JP 2003-233517. 2 English language Abstract of JP 2002-116935. 3 English language Abstract of JP 2001-249693. 4 U.S. Patent Application No. 10/577,418 to MAEDA et al, which was filed on April 27, 2006. 5 U.S. Patent Application No. 10/578,373 to SO et al., which was filed on May 5, 2006. 6 U.S. Patent Application No. 10/578,372 to MAEDA et al., which was filed on May 5, 2006. 7 U.S. Patent Application No. 10/596,155 to SO et al., which was filed on June 1, 2006. 8 /T.V./ DATE CONSIDERED 11/30/2007 **EXAMINER** /Truong Vo/ EXAMINER: Initial if citation considered, whether or not citation is in conformance with MPEP 609; draw line through citation if not in conformance and not considered. Include copy of this form with next communication to applicant.